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STATEMENT BY APPLICANT

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Application Number	09/857,859			
Filing Date	06/11/2001			
First Named Inventor	Dr. Bernd HEINEMANN			
Group Art Unit				
Examiner Name				
Attorney Docket Number	7040-30			

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Examiner Name				
Attorney Docket Number	7040-30			

OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS						
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²			
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Examiner Signature	7.	NAMEN	Date Considered	7/11/03

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